

Supporting Information

for

A robust AFM-based method for locally measuring the elasticity of samples

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Analytical expression for normal sample stiffness

The following computation steps establish the analytical expression for normal sample stiffness [1]. The formula is derived from the equations stated by Hurley and Turner [2] for the numerical determination of normal sample stiffness. These equations, i.e., equations (1), (2), (3), (4), (5), (6) and (7), are based on the description of the dynamics of a clamped, ideally beam-shaped cantilever elastically coupled to a sample by its tip, published by Rabe [3] and Rabe and co-workers [4]. The model takes into account characteristics of the cantilever, such as tilt angle α and dimensions, namely total length L , length from the clamped end to the tip L_1 , length from the tip to the free end L_2 , tip height h , but also characteristics of the sample, i.e., normal sample stiffness $k_{sample,norm}$ and lateral sample stiffness $k_{sample,lat}$ represented by two springs coupled to the cantilever tip, as shown in Figure S1.

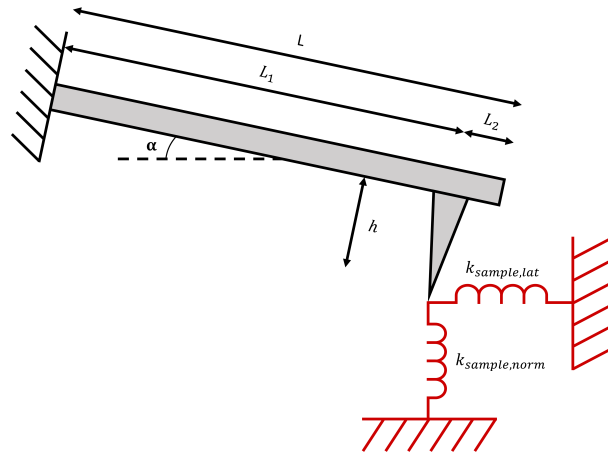


Figure S1: Modelization of clamped beam-shaped cantilever elastically coupled to a sample by its tip and used for the computation of normal sample stiffness. The cantilever characteristics, i.e. L , L_1 , L_2 , h and α correspond, respectively, to cantilever length, length from the clamped end to the tip, length from the tip to the free end, tip height and tilt angle. The springs $k_{sample,norm}$ and $k_{sample,lat}$ stand, respectively, for normal and lateral sample stiffnesses.

Wavenumbers x_n and y_n associated with the measured n^{th} flexural contact resonance f_n and torsional contact resonances t_n are computed by

$$x_n L = x_n^0 L \sqrt{\frac{f_n}{f_n^0}},$$

where f_n^0 is the cantilever resonance of n^{th} flexural mode in free space and x_n^0 the associated wavelength (values given in Rabe [3]) obtained from the resolution of the characteristic equation $\cos(x_n L) \cosh(x_n L) + 1 = 0$ and

$$y_n = \frac{(2n-1)\pi t_n}{2 t_n^0},$$

where t_n^0 is the cantilever resonance of n^{th} torsional mode in free space.

The normalized lateral contact stiffness is determined by

$$k_{sample,lat} = -\frac{y_n L \cos(y_n L)}{\sin(y_n L_1) \cos(y_n L_2)} k_{lat},$$

where k_{lat} is the lateral cantilever stiffness constant.

The normal contact stiffness normalized with the cantilever flexural stiffness constant k_1 is obtained from the expression

$$\frac{k_{sample,norm}}{k_1} = \frac{-B \pm \sqrt{B^2 - 4AC}}{6A}, \quad (1)$$

where the positive root corresponds to the normalized contact stiffness and parameters A, B and C are defined by

$$A = \frac{k_{sample,lat}}{k_{sample,norm}} A', \quad (2)$$

where

$$A' = \left(\frac{h}{L_1}\right)^2 \left(1 - \cos(x_n L_1) \cosh(x_n L_1)\right) \left(1 + \cos(x_n L_2) \cosh(x_n L_2)\right),$$

$$B = B_1 + B_2 + B_3, \quad (3)$$

with

$$B_1 = \left[\sin^2(\alpha) + \left(\frac{k_{sample,lat}}{k_{sample,norm}} \right) \cos^2(\alpha) \right] B'_1, \quad (4)$$

where

$$B'_1 = \left(\frac{h}{L_1} \right)^2 (x_n L_1)^3 \left[\left(1 + \cos(x_n L_2) \cosh(x_n L_2) \right) \left(\sin(x_n L_1) \cosh(x_n L_1) + \cos(x_n L_1) \sinh(x_n L_1) \right) - \left(1 - \cos(x_n L_1) \cosh(x_n L_1) \right) \left(\sin(x_n L_2) \cosh(x_n L_2) + \cos(x_n L_2) \sinh(x_n L_2) \right) \right],$$

$$B_2 = \left[\left(\frac{k_{sample,lat}}{k_{sample,norm}} - 1 \right) \cos(\alpha) \sin(\alpha) \right] B'_2, \quad (5)$$

where

$$B'_2 = 2 \left(\frac{h}{L_1} \right) (x_n L_1)^2 \left[\left(1 + \cos(x_n L_2) \cosh(x_n L_2) \right) \sin(x_n L_1) \sinh(x_n L_1) + \left(1 - \cos(x_n L_1) \cosh(x_n L_1) \right) \sin(x_n L_2) \sinh(x_n L_2) \right],$$

Factor 2, that does not appear in Hurley and Turner [2], is actually a necessary correction, as introduced by Steiner et al. [5],

$$B_3 = \left[\cos^2(\alpha) + \left(\frac{k_{sample,lat}}{k_{sample,norm}} \right) \sin^2(\alpha) \right] B'_3, \quad (6)$$

where

$$B'_3 = x_n L_1 \left[\left(1 + \cos(x_n L_2) \cosh(x_n L_2) \right) \left(\sin(x_n L_1) \cosh(x_n L_1) - \cos(x_n L_1) \sinh(x_n L_1) \right) \right. \\ \left. - \left(1 - \cos(x_n L_1) \cosh(x_n L_1) \right) \left(\sin(x_n L_2) \cosh(x_n L_2) - \cos(x_n L_2) \sinh(x_n L_2) \right) \right],$$

and

$$C = 2(x_n L_1)^4 (1 + \cos(x_n L) \cosh(x_n L)). \quad (7)$$

Parameter B can be split into two terms, one with $k_{sample,norm}$ and the other without;

$$B = \beta_1 + \beta_2 \frac{k_{sample,lat}}{k_{sample,norm}},$$

with

$$\beta_1 = \sin^2(\alpha) B'_1 - \cos(\alpha) \sin(\alpha) B'_2 + \cos^2(\alpha) B'_3,$$

and

$$\beta_2 = \cos^2(\alpha) B'_1 + \cos(\alpha) \sin(\alpha) B'_2 + \sin^2(\alpha) B'_3.$$

By setting a new variable ε of expression

$$\varepsilon = 6A' \frac{k_{sample,lat}}{k_1},$$

we can rewrite equation (1) as

$$\varepsilon + B = \pm \sqrt{B^2 - 4AC}.$$

Finally, by squaring each side of the equation and isolating $k_{sample,norm}$, we find the following expression for the normal sample stiffness

$$k_{sample,norm} = -\frac{2A' C \varepsilon^{-1} + \beta_2}{0.5\varepsilon + \beta_1} k_{sample,lat}.$$

References

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